

Electronic Supplementary Information

3D hierarchical self-supported NiO/Co₃O₄@C/CoS₂ nanocomposites as electrode materials for high-performance supercapacitor

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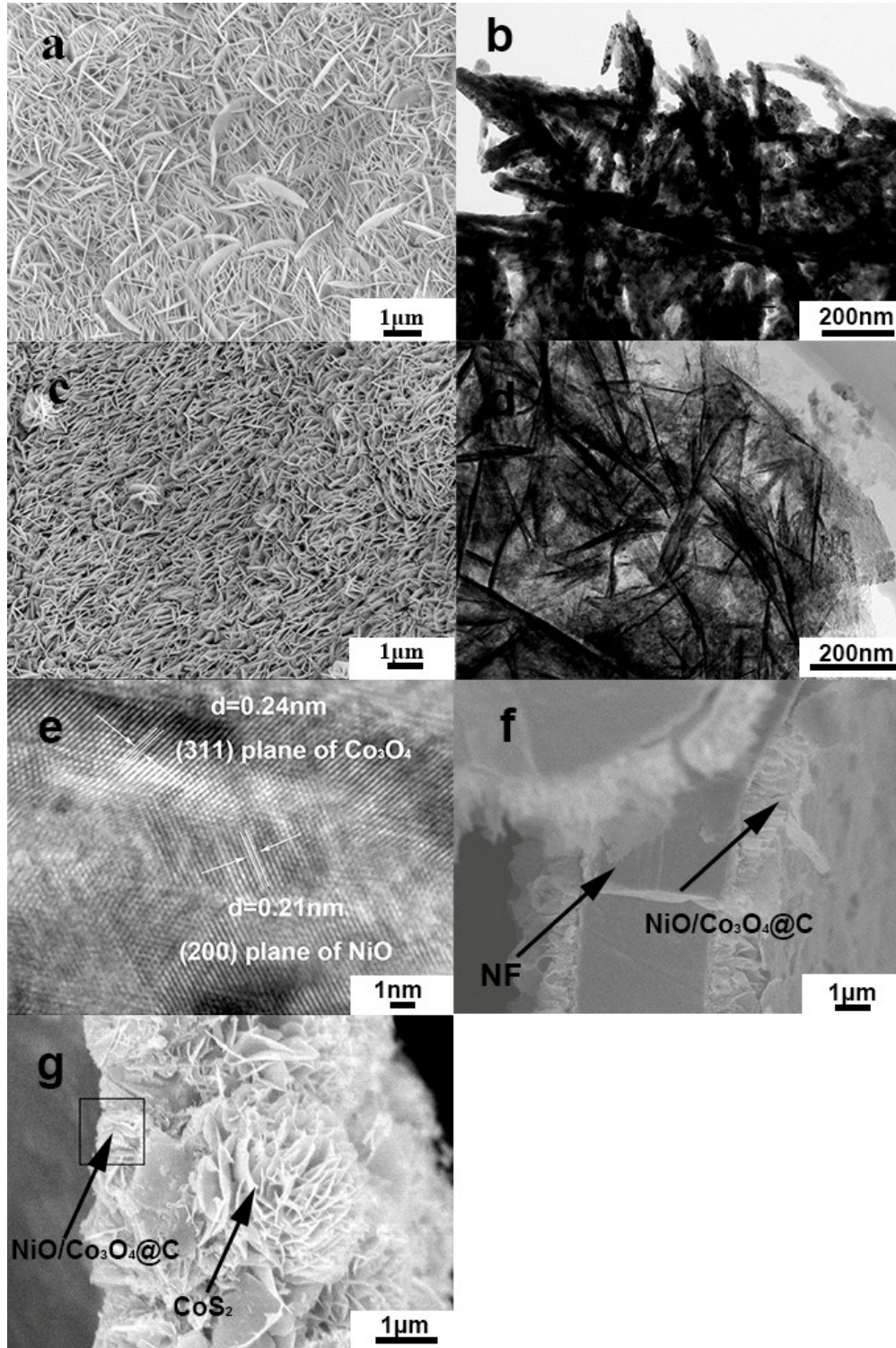


Fig. S1. (a) The typical SEM image of the Ni-Co LDH. (b) The typical TEM image of the Ni-Co LDH (c) The typical SEM image of the NiO/Co₃O₄@C. (d) The typical TEM image of NiO/Co₃O₄@C. (e)HRTEM image of NiO/Co₃O₄@C. The cross section of NiO/Co₃O₄@C and NiO/Co₃O₄@C/CoS₂ (f, g).

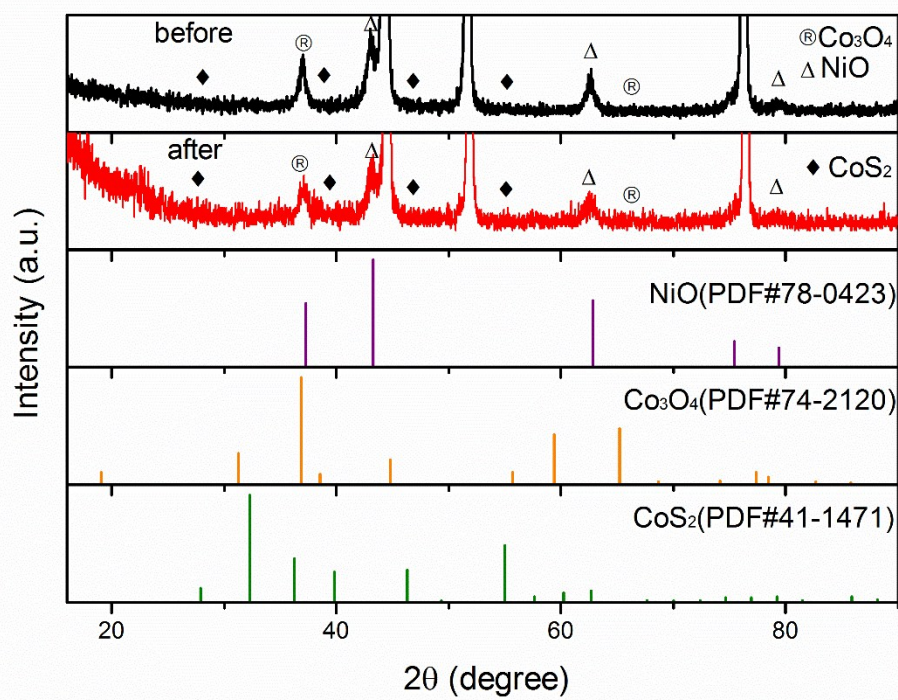


Fig. S2 The XRD results of NiO/Co₃O₄@C/CoS₂ sample before and after 5000 cycles.

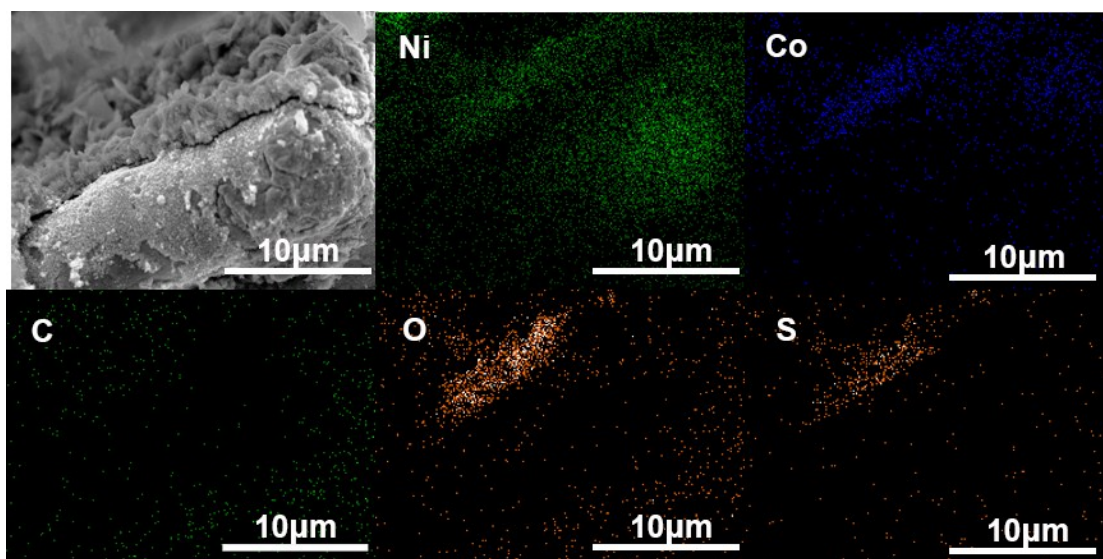


Fig. S3 Area distribution of S, Co, O, C and Ni elements in NiO/Co₃O₄@C/CoS₂.

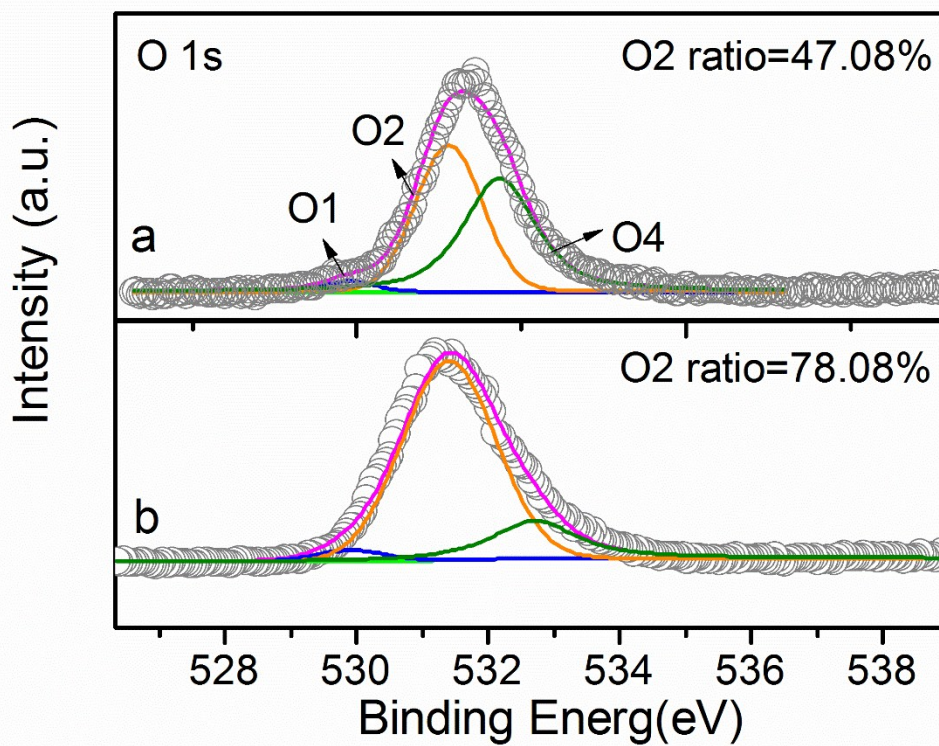


Fig. S4 Fitted O 1s for NiO@Co₃O₄@C (a) and for NiO/Co₃O₄@C/CoS₂(b).

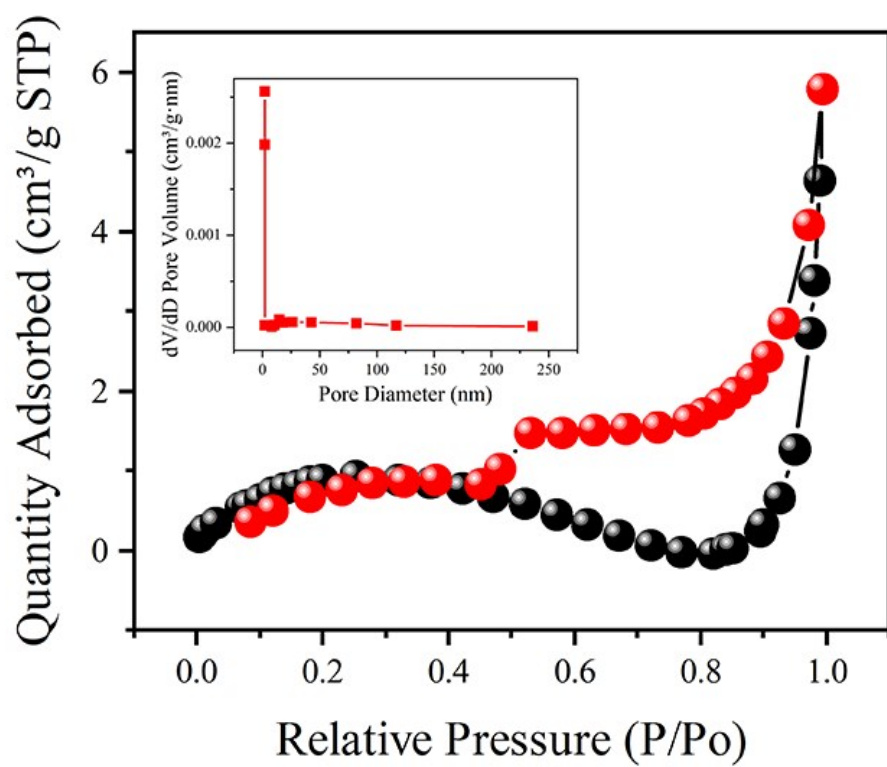


Fig. S5 Nitrogen adsorption–desorption isotherms and pore-size distribution (inset) of nickel foam coated with NiO/Co₃O₄@C sample.

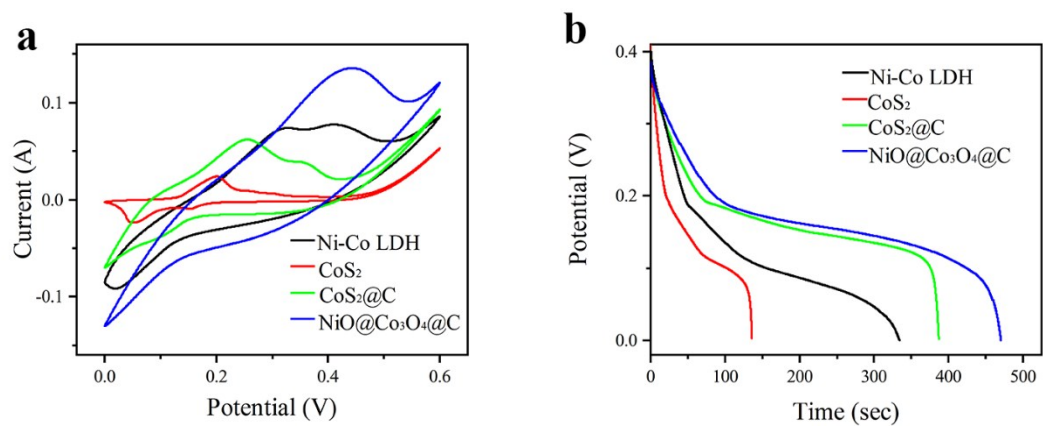


Fig. S6 The CV (a) and GCD (b) curves of as-prepared samples at scan rate 50 mV s^{-1} and current density of 2 A g^{-1} .

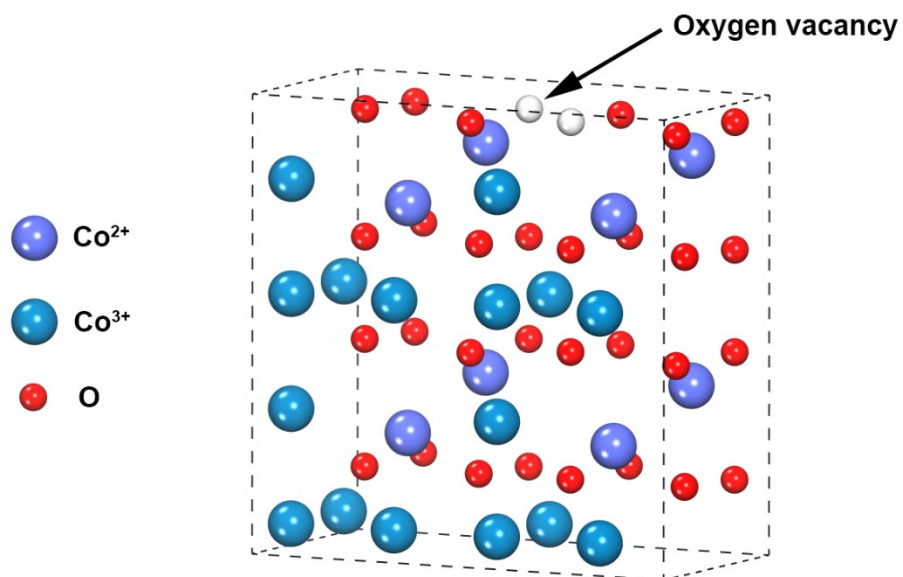


Fig. S7 Illustration of more oxygen vacancies presence in the surface of Co_3O_4 during the reaction of $\text{Co}^{3+} + \text{S}_2\text{O}_3^{2-} + 5\text{H}_2\text{O} = 8\text{Co}^{2+} + 2\text{SO}_4^{2-} + 10\text{H}^+$.

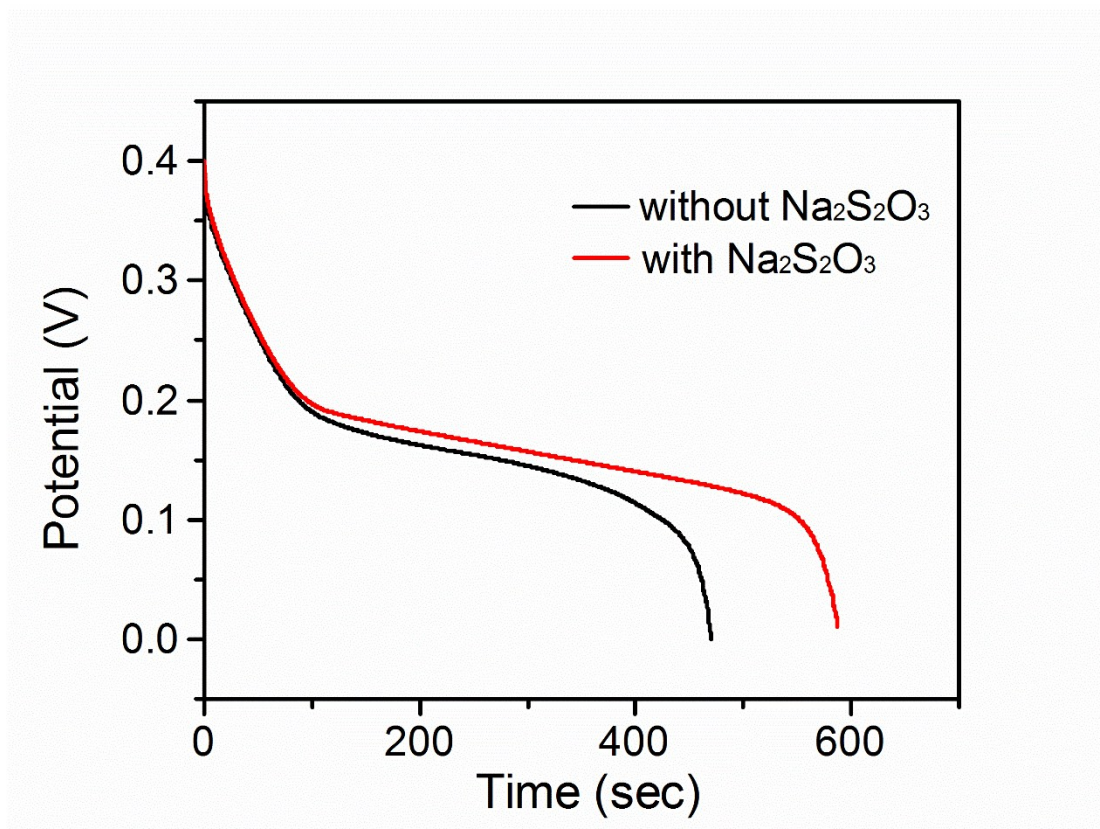


Fig. S8 GCD curves of the samples with or without Na₂S₂O₃.

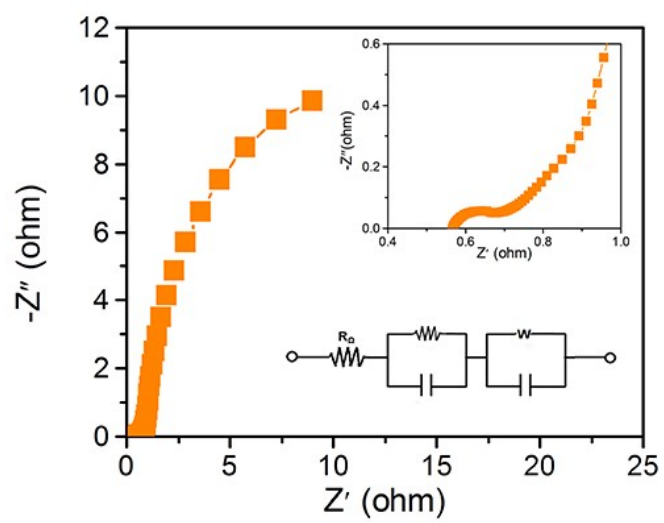


Fig. S9 Nyquist plot of the NiO/Co₃O₄@C/CoS₂ electrode with its equivalent circuit (inset) used to fit the experimental data.

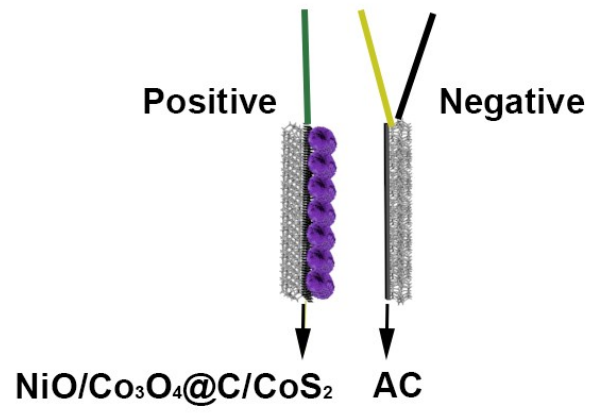


Fig. S10 Hybrid device of $\text{NiO/Co}_3\text{O}_4\text{@C/CoS}_2\text{//AC}$.

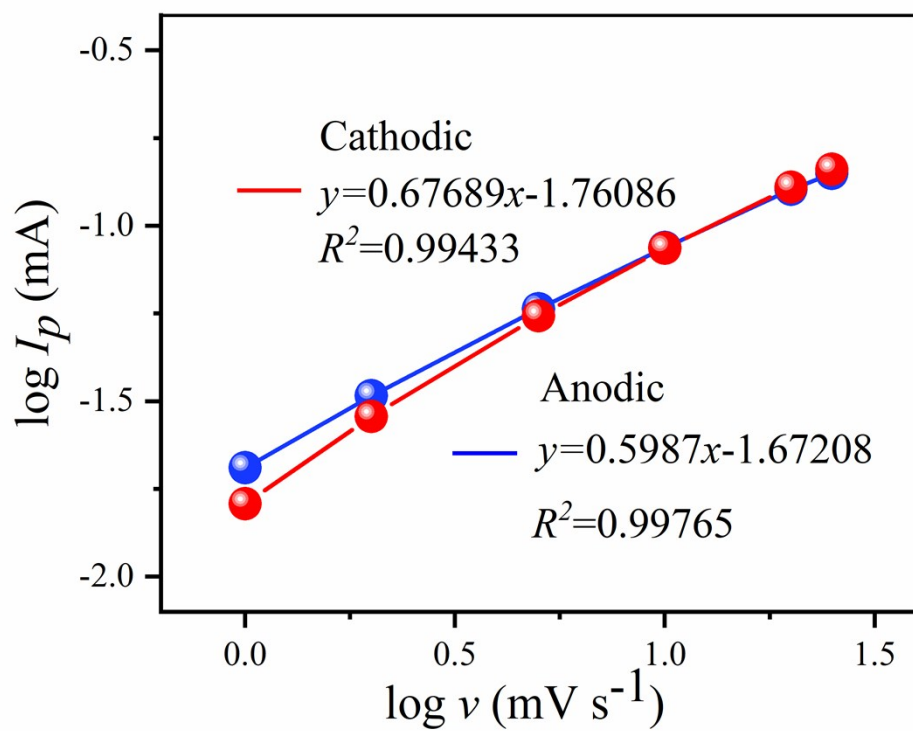


Fig. S11 The electrochemical behavior of NiO/Co₃O₄@C/CoS₂.

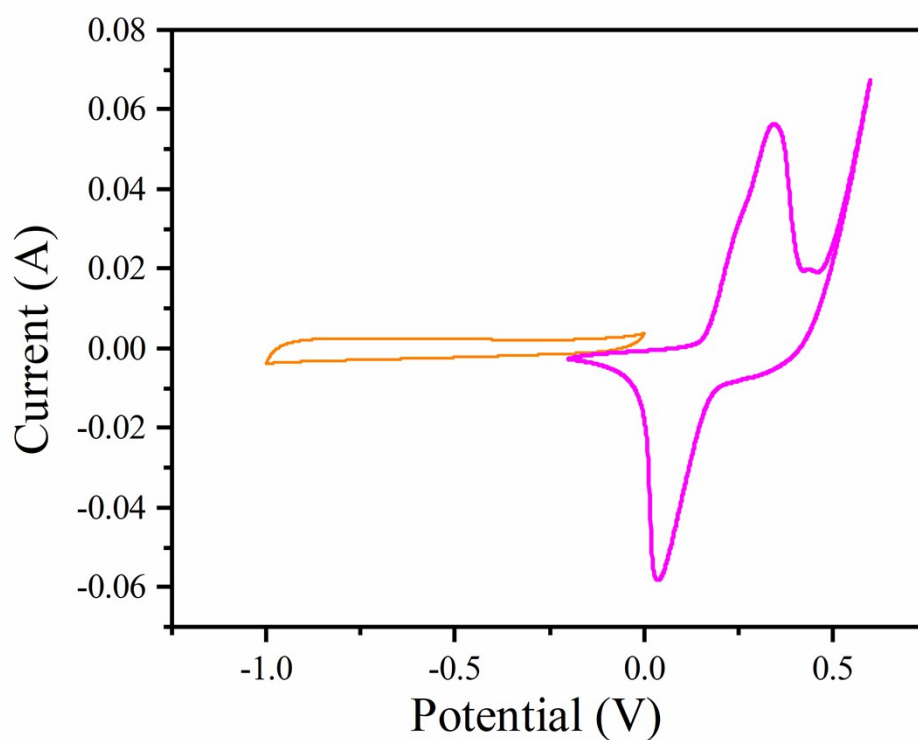


Fig. S12 Cyclic voltammograms of the NiO/Co₃O₄@C/CoS₂ electrode and activated carbon (AC) electrodes performed in a three-electrode system in 6 M KOH solution at a scan rate of 5 mV s⁻¹.

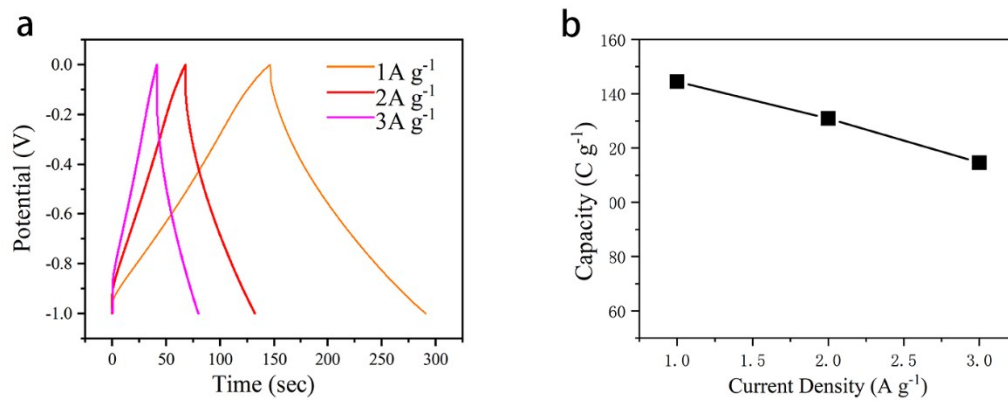


Fig. S13 (a) GCD curves of AC electrode at various current densities. (b) Rate performance of the AC electrode at various scan rates from 1 A g⁻¹ to 3 A g⁻¹.

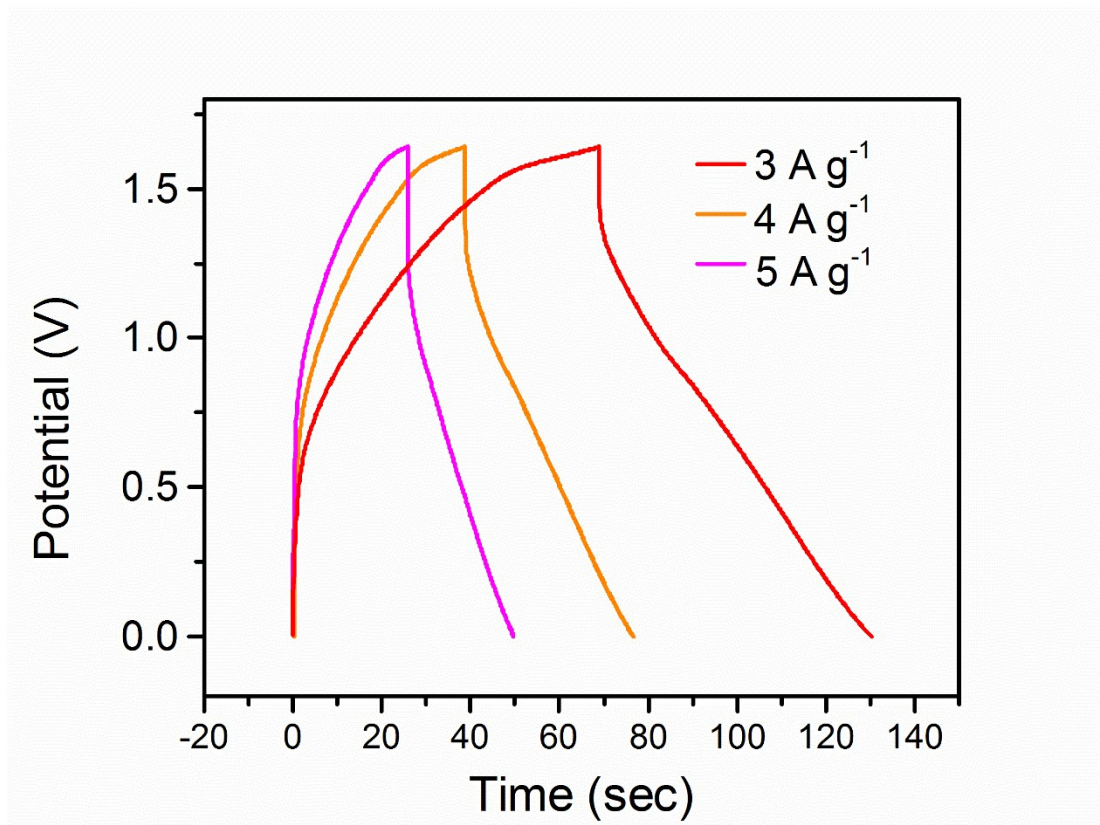


Fig. S14 GCD curves of NiO/Co₃O₄@C/CoS₂//AC hybrid device at different current densities.

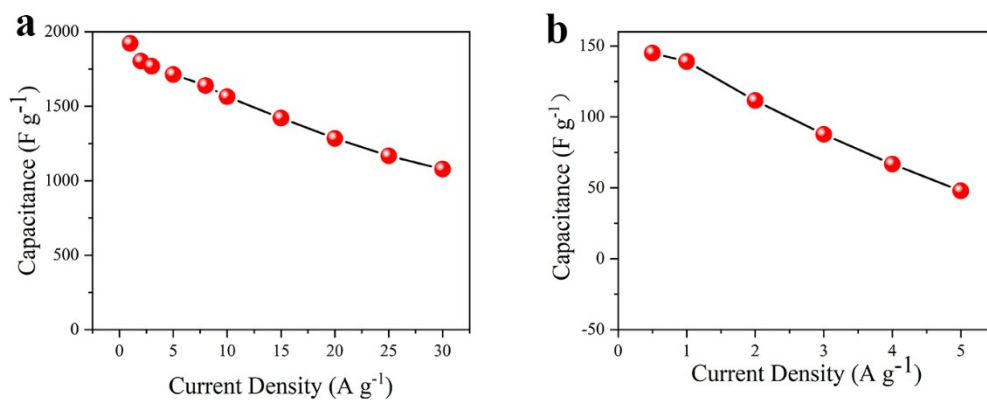


Fig. S15 Rate performance of NiO/Co₃O₄@C/CoS₂ hybrid electrode at various scan rates from 1 A g⁻¹ to 30 A g⁻¹; (b) Rate performance of NiO/Co₃O₄@C/CoS₂//AC hybrid device at various scan rates from 0.5 A g⁻¹ to 5 A g⁻¹.

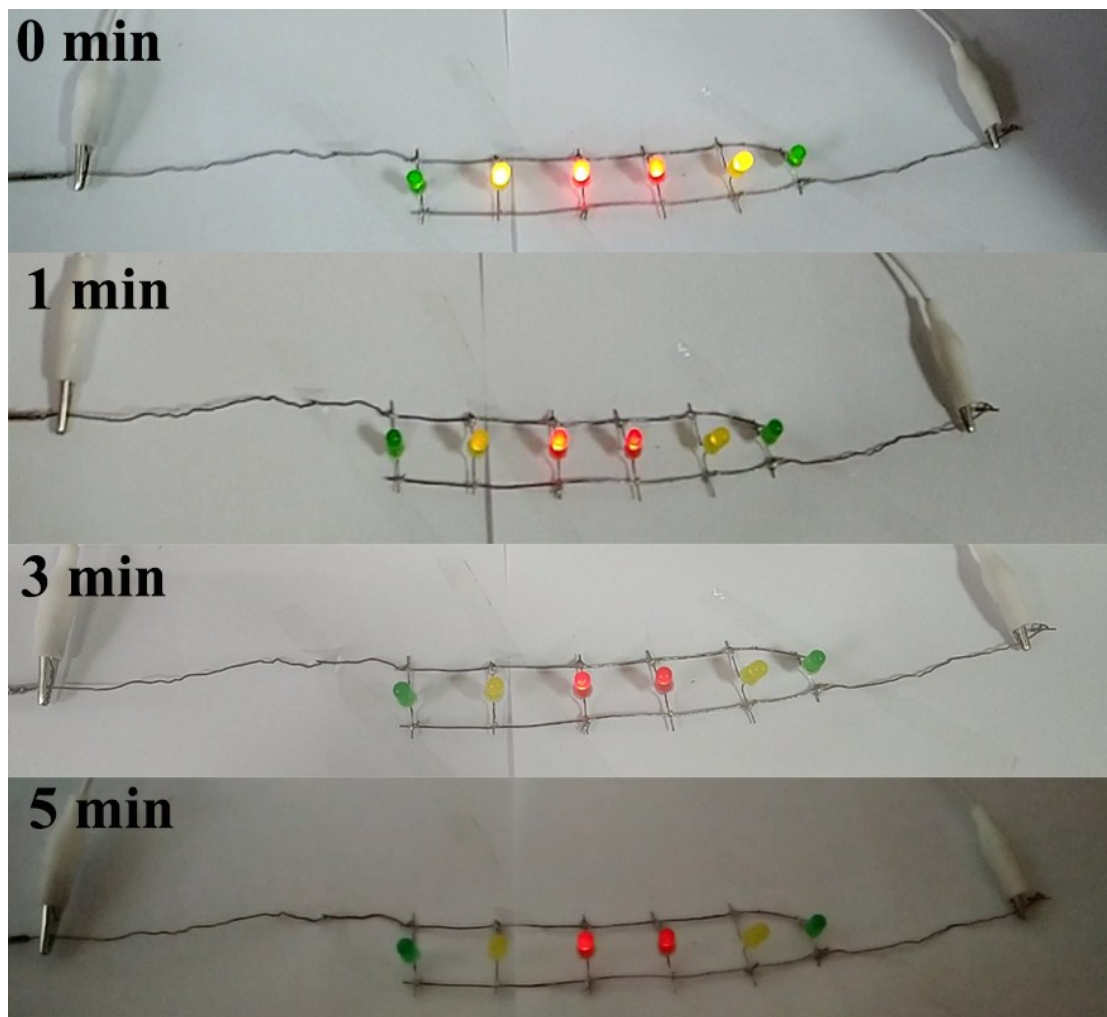


Fig. S16 Real application of the two $\text{NiO}/\text{Co}_3\text{O}_4@\text{C}/\text{CoS}_2//\text{AC}$ devices for lighting six LEDs at the same time.

Table S1 Comparison of electrochemical performance of some reported electrode materials.

Samples	Highest capacity (F g ⁻¹)	High rate performance	Ref
G-Ni(OH) ₂ /MoS ₂	1950 F g ⁻¹ at 1 A g ⁻¹	1400 F g ⁻¹ at 1 A g ⁻¹	1
NiCo ₂ O ₄ /NiO/ Co ₃ O ₄	1693 F g ⁻¹ at 1 A g ⁻¹	~1480 F g ⁻¹ at 10 A g ⁻¹	2
Co ₃ O ₄ - NiO/graphene foam	783 F g ⁻¹ at 1 A g ⁻¹	583 F g ⁻¹ at 10 A g ⁻¹	3
MnO ₂ @NiCo- LDH/CoS ₂	1547 F g ⁻¹ at 1 A g ⁻¹	1189 F g ⁻¹ at 10 A g ⁻¹	4
CoO/Co-Cu-S	2300 F g ⁻¹ at 2 A g ⁻¹	~1702 F g ⁻¹ at 30 A g ⁻¹	5
NiO/Co ₃ O ₄ @C/ CoS ₂	1024 C g ⁻¹ at 1A g ⁻¹	~759 C g ⁻¹ at 30 A g ⁻¹	This work

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